

Computational Microelectronics Report (Homework #4)

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Major: Electrical Engineering and Computer Science

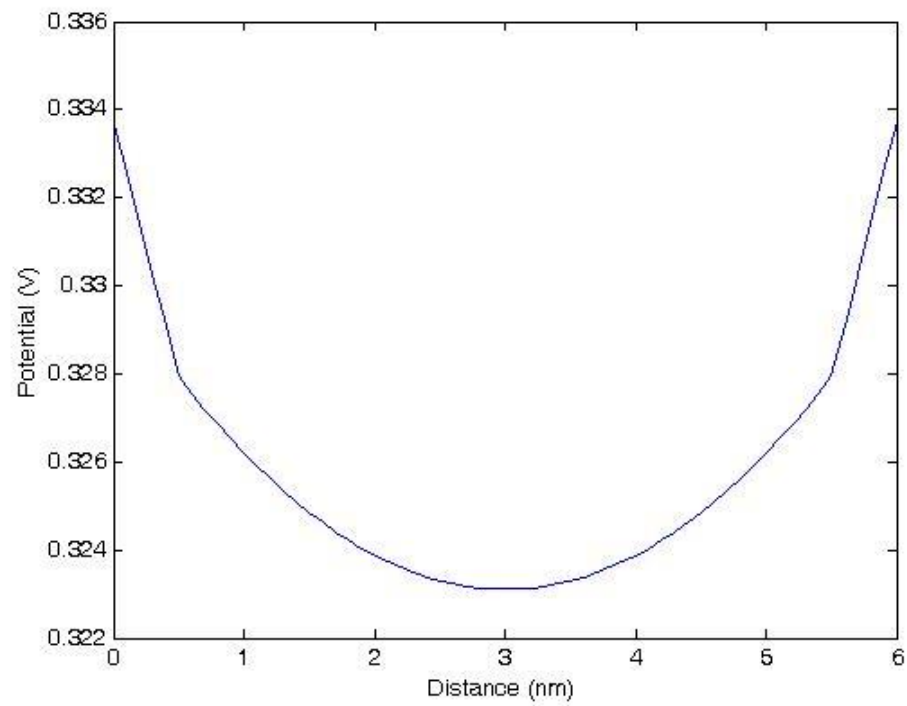
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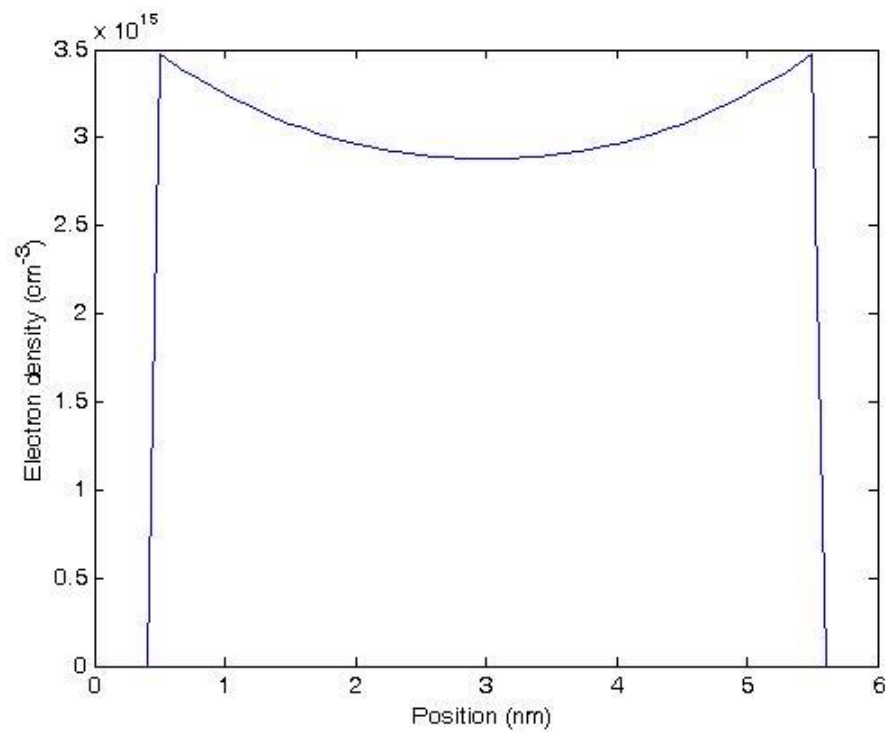
Submission Date: 2018.10. 01



1. Electrostatic potential under initial condition (The applied voltage is 0V.)

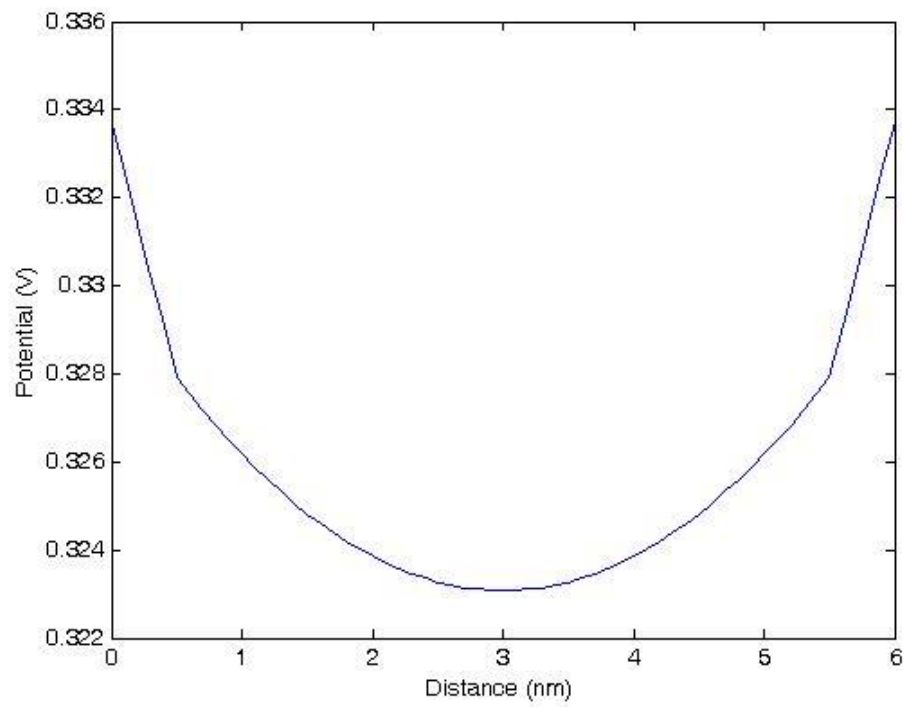


2. Electron density under initial condition (The applied voltage is 0V.)

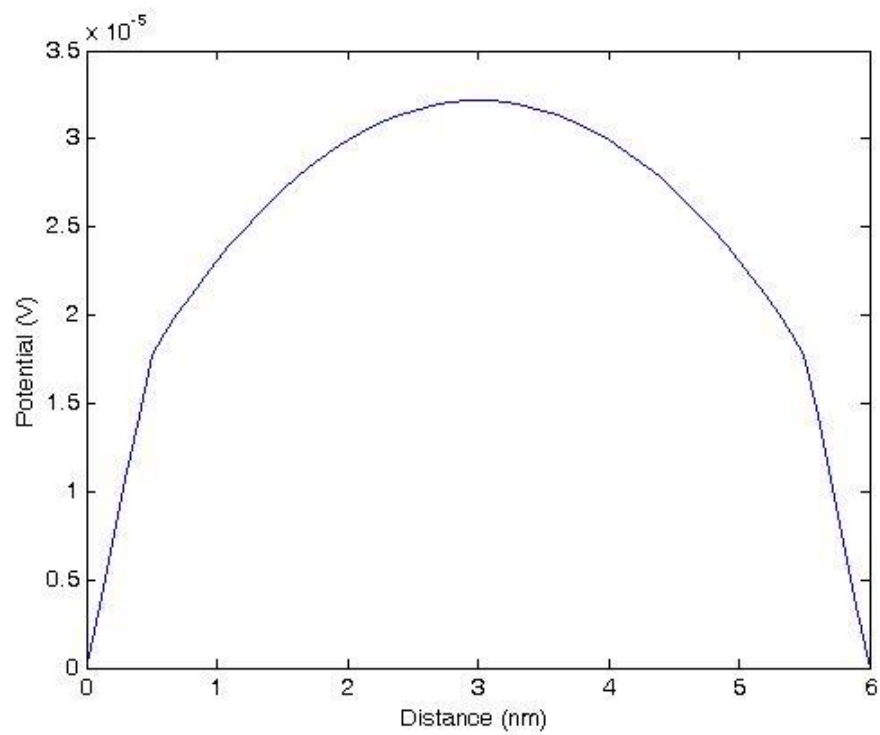


3. Re-calculated potential

3-1. Re-calculated potential



3-2. Difference between 1 and 3-1



The potential in silicon makes the difference because $n(x)$ is so small that it is ignored.

4. Difference for several gate voltages from 0V to 1V

